

**INFORMATION DISCLOSURE CITATION**  
(Use several sheets if necessary)

Docket Number (Optional)  
**P-6101**

Application Number  
**10/668,725**

Applicant(s)  
**ALHEIDT ET AL.**

Filing Date  
**9/23/03**

Group Art Unit  
**3763**

**U.S. PATENT DOCUMENTS**

*EXAMINER INITIAL	REF	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
/CSW/		3,050,059	8/21/62	WALL ET AL.			5/25/59
		4,057,052	11/8/77	KAUFMAN ET AL.			10/26/76
		5,496,285	3/5/96	SCHUMACHER ET AL.			11/18/94
		5,902,271	5/11/99	JENTZEN			4/1/88
		6,361,524	3/26/02	ODELL ET AL.			4/14/98
		6,171,287B1	1/9/01	LYNN ET AL.			5/28/99
		5,807,374	9/15/98	CAIZZA ET AL.			8/14/77
/CSW/		5,037,393	8/6/91	ELLGASS			

**FOREIGN PATENT DOCUMENTS**

	REF	DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	Translation	
							YES	NO
/CSW/		GB 2197792A						

**OTHER DOCUMENTS** (Including Author, Title, Date, Pertinent Pages, Etc.)


EXAMINER /Catherine S. Williams/ (09/13/2007)

DATE CONSIDERED

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# INFORMATION DISCLOSURE CITATION

(Use several sheets if necessary)

Docket Number (Optional)

P-6106

Application Number

10/668,725

Applicant(s)

Alhedit et al.

Filing Date

9/23/03

Group Art Unit

## U.S. PATENT DOCUMENTS

*EXAMINER INITIALS	REF	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
/CSW/		2004/0010235A1	1/15/04	Weilbacher et al.	604	218	7/11/02

## FOREIGN PATENT DOCUMENTS

	REF	DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	Translation	
							YES	NO

## OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)


EXAMINER

/Catherine S. Williams/ (09/13/2007)

DATE CONSIDERED

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